



**DA-IICT**  
**EL401 PHYSICS OF SEMICONDUCTOR DEVICES**  
**SEMESTER – AUTUMN 2024-25**  
**QUIZ 4 ( Nov 7,2024)**

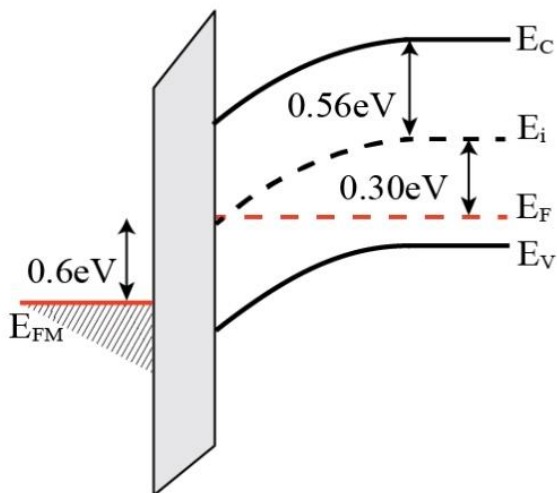
**Time: 20 mints**

**Max Marks 2X5=10**

**NOTE:** Books, notes and calculator is allowed. The solution must be shown step by step.

The energy band diagram of a MOSCAP device is sketched in the figure below. Assume that the electrostatic potential is zero in the semiconductor bulk, (i.e. at large distance from Si-SiO<sub>2</sub> interface) and that there is no metal-semiconductor work function difference.

(Take  $\epsilon_{ox}=3.9$ ,  $kT=26\text{meV}$ ,  $E_g=1.1\text{eV}$ ,  $\epsilon_{si}=11.8\epsilon_{ox}=3.9$ ,  $n_i=10^{10}\text{cm}^{-3}$  )



**Q1.** What is the value of  $\phi_F$  ?

**ANS:**

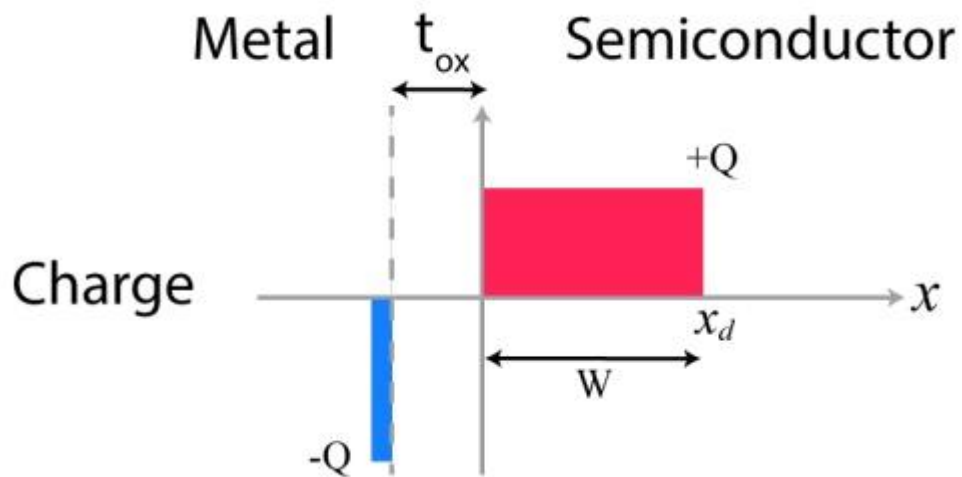
**Q2.** What is the applied gate voltage,  $V_G$  ?

**ANS:**

**Q3.** What is the doping density,  $N_A$  in  $\text{cm}^{-3}$  ?

**ANS:**

Q4. The charge block diagram of a semiconductor is shown below:



Q4. Draw the E-field plot corresponding to given charge diagram?

Ans:

Q5. Which is the correct Electrostatic potential wrt X?

